

A Type II n-n Staggered Orthorhombic V₂O₅/ Monoclinic Clinobisvanite BiVO₄ Heterojunction Photoanode for Photoelectrochemical Water Oxidation: Fabrication, Characterisation and Experimental Validation

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Abstract

Conventional photoanode using a singular semiconductor material is not technically viable for photoelectrochemical (PEC) water oxidation owing to the properties relating to its wide band gap, sluggish charge mobility, as well as poor separation and rapid recombination of photogenerated charge carriers. The main aim of this study was to fabricate an *n-n* heterojunction photoanode of $V_2O_5/BiVO_4$ via a facile electrodeposition synthesis method in order to overcome the technical bottlenecks encountered in conventional singular photoanode structures. Additionally, the synergistic effect of band potentials matching and conductivity difference between $BiVO_4$ and V_2O_5 were studied using LSV, IMPS, EIS, HR-TEM, XRD, XPS, Raman and ultraviolet-visible spectroscopies. This was followed by the performance evaluation of the light-induced water splitting using a standard three-electrode assembly PEC cell under 1.5 AM solar simulator. Results showed that the $V_2O_5/BiVO_4$ heterojunction photoanode achieved a significantly improved photocurrent density of 1.53 mA/cm^2 at 1.5 V vs Ag/AgCl, which was a 6.9-fold and a 7.3-fold improvement over the individual pristine $BiVO_4$ (0.22 mA/cm^2) and V_2O_5 (0.21 mA/cm^2), respectively. The improvement was attributed to the lower charge resistances at the FTO/semiconductor, semiconductor/FTO and semiconductor/electrolyte interfaces as well as the fast transit time (τ) of 6.4 millisecond for photo-injected electrons in the $V_2O_5/BiVO_4$ heterojunction photoanode. Finally, the experimental results were used to reconstruct a theoretical band diagram in validating the heterojunction alignment between V_2O_5 and $BiVO_4$ as well as in elucidating the photogenerated charge carriers transfer mechanism in the $V_2O_5/BiVO_4$ heterojunction photoanode.

Key words: Bismuth vanadate; *n-n* heterojunction; Photoelectrocatalysis; Charge separation

1. Introduction

Photoelectrochemical (PEC) water splitting, also known as artificial photosynthesis, is a green route for sustainable hydrogen (H_2) production by harnessing the largest abundant renewable solar energy and convert them into chemical fuels [1]. However, the PEC-based technology for water splitting has yet to be commercialised due to the high H_2 production cost and significant efficiency losses with oxygen (O_2) production [2]. In this instance, the identification of a suitable semiconductor-based photoelectrode for PEC water splitting plays an important role in reducing the costs of materials and processes as well as improving the H_2 yield [3]. There are a few important considerations that must be taken into account when considering the type of semiconductor photoelectrode used, such as: (1) appropriate alignment of conduction (CB) and valence band (VB) edge positions for H_2 and O_2 generations, respectively, (2) being a good light absorber by possessing a reasonably narrow band gap that could be activated under the visible light spectrum, and (3) stable against most of the chemical and photochemical externalities [4].

To date, various type of semiconductor photoelectrodes (e.g. TiO_2 , Fe_2O_3 , WO_3 and $BiVO_4$) have garnered significant interests and exploitation for PEC water splitting after the pioneering work by Fujishima and Honda in 1972 [5]. Among the suitable candidate of semiconductor photoelectrodes, ternary metal oxides monoclinic $BiVO_4$ is one of the most promising photoanode candidates used for PEC water splitting under visible light [6]. Theoretically, $BiVO_4$ is able to absorb a substantial portion of visible range spectrum due to it is having a direct band gap of 2.5 eV. Additionally, $BiVO_4$ also has a favourable CB edge position near 0 V_{RHE} and exhibits high resistance towards photoinduced corrosion near neutral aqueous condition due to its oxygen evolution reaction (OER), which is slightly more positive than the

water oxidation potential [7]. Based on its band gap energy, the theoretical maximum solar-to-hydrogen (STH) efficiency for BiVO₄ is approximately 9.1%, while the theoretical maximum photocurrent density is approximately 6.47 mA/cm² at 1.23 V_{RHE} under 1 Sun illumination [8].

Despite the multi-merits of BiVO₄ used as a photoanode in PEC water oxidation, the practical potential is still far reaching from its full potential in terms of the photocurrent generation [9]. This is due to that BiVO₄ is suffering from its inherent material drawbacks, such as poor separation of photogenerated charge carriers and high bulk and surface recombination, which predominantly cause by the sluggish charge mobility of the electron-hole pairs [10]. In this aspect, the mobility of the photogenerated electrons is limited by the distance between the VO₄ tetrahedra of pristine BiVO₄ crystal (i.e. V-3d orbitals where the CB lie), while the transfer of photogenerated holes across the semiconductor-electrolyte interface depends on the kinetics of four-electron water oxidation reaction [10]. Thus, the most commonly reported photocurrent generation values in the literature for using pristine BiVO₄ as the photoanode in PEC water oxidation are approximately 0.5 mA/cm² [11].

Various surface and interfacial modifications have been made thus far to improve the PEC performance of pristine BiVO₄, such as the introduction of metal dopants as active recombination centers [12-15], coupling of BiVO₄ with OER catalyst to improve the mobility of photogenerated charge carriers during water oxidation reaction [16-19], and the incorporation of BiVO₄ with other semiconductors to form heterojunction photoelectrode to promote effective transfer of photogenerated charge carriers [16, 20-23]. As of recent, the fabrication of heterojunction photoelectrode by creating a region with electric potential gradients between the interfaces of two semiconductors is proven to be an effective approach for good separation and transfer rate of photogenerated charge carriers [24]. Typically, there are three type of

heterojunction alignments between two semiconductors and they are Type I: Straddling gap, Type II: Staggered gap and Type III: Broken gap, depending on their band gap properties and alignment of CB and VB edges. Cheng et al. discussed that the Type II heterojunction alignment is the most potent structure to overcome the poor separation of photogenerated charge carriers in semiconductors [25].

Previous studies have attempted the fabrication of heterojunction photoanodes of BiVO₄ with WO₃ [26, 27], ZnO [28, 29] and TiO₂ [25, 30]. However, the photocurrent generation was ranging from 0.8 – 6.72 mA/cm² at 1.23 V vs RHE where the heterojunction photoanodes with the highest photocurrent reported to date is CoPi-coated WO₃/BiVO₄ with 6.72 mA/cm² at 1.23 V vs RHE [27]. From the literature, it was evidenced that there are no previous work that considered on forming heterojunction photoanode between BiVO₄ and vanadium pentoxide (V₂O₅) for PEC water oxidation. V₂O₅ is an infrequently studied *n*-type semiconductor for PEC water splitting with a band gap energy of 2.3 eV, which is smaller than that of BiVO₄. This enables V₂O₅ to absorb visible light more efficiently, and its band edge potentials are able to straddle the redox potential of water at 1.23 eV [31]. The formation of heterojunction photoanodes between V₂O₅ and other semiconductors, such as TiO₂ [32], ZnO [33] and g-C₃N₄ [34] is able to promote the photocatalytic efficiency by extending the range of light absorption as well as improving the charge mobility and the good separation of photogenerated charge carriers. This study aimed to fabricate an *n-n* heterojunction photoanode of V₂O₅/BiVO₄ via a facile electrodeposition synthesis method over the transparent and conductive fluorine-doped tin oxide (FTO) substrate. The synergistic effect of band potentials matching and conductivity difference between BiVO₄ and V₂O₅ were studied using linear sweep voltammetry (LSV), intensity modulated photocurrent spectroscopy (IMPS), electrochemical impedance spectroscopy (EIS),

high resolution-transmission electron microscopy (HR-TEM), X-ray diffractometer (XRD), X-ray photoelectron spectroscopy (XPS), Raman spectroscopy and ultraviolet-visible (UV-vis) spectroscopy. This was followed by the performance evaluation of the light-induced water splitting using a standard three-electrode assembly PEC cell under 1.5 AM solar simulator. Finally, the experimental results were used to reconstruct a theoretical band diagram in validating the heterojunction alignment between V_2O_5 and $BiVO_4$ as well as in elucidating the photogenerated charge carriers transfer mechanism in the $V_2O_5/BiVO_4$ heterojunction photoanode.

2. Experimental Section

2.1. Materials

Bismuth nitrate pentahydrate ($Bi(NO_3)_3 \cdot 5H_2O$) was purchased from R&M Chemicals, United Kingdom. Anhydrous sodium acetate (CH_3COONa) was purchased from Chem Soln, while vanadium (IV) oxide sulfate hydrate ($VOSO_4$, 97%) was obtained from Sigma Aldrich, USA. Nitric acid (HNO_3 , 69%) was obtained from Friendemann Schmidt Chemical, Germany; absolute ethanol (C_2H_6O), sulfuric acid (H_2SO_4 , 95-98%) and sodium sulfate (Na_2SO_4) were purchased from Merck, Germany; FTO glass was purchased from Kaivo Optoelectronic Technology, China. All the reagents were of analytical grade and used without further purification.

2.2. Fabrication of BiVO₄ and V₂O₅/BiVO₄ photoanodes

FTO substrates were cleaned using acetone, ethanol, and deionised water in an ultrasonic bath for 20 min before being dried in the oven. BiVO₄ photoanode was synthesized via a facile electrodeposition synthesis method in a three-electrode PEC cell that comprised of a FTO, a Pt rod, and a Ag/AgCl (3M) electrode used as the working, counter, and reference electrodes, respectively. The electrodeposition synthesis method of monoclinic clinobisvanite BiVO₄ was adapted from Seabold *et al* [7]. Briefly, 35 mM VOSO₄ were dissolved in 0.5 M HNO₃, and 10 mM Bi(NO₃)₃ were then added. Thereafter, 2 M CH₃COONa solution was used to increase the pH of the mixture to pH 5.1 and stabilise the Bi(III) ions otherwise it will insoluble at pH 4.7. The final pH of the mixture was adjusted to pH 4.7 using HNO₃. The electrodeposition synthesis process was conducted potentiostatically with an applied potential of 1.9 V vs Ag/AgCl (3M) for 45 min on bare FTO and FTO/V₂O₅. After that, the as-deposited amorphous BiVO₄ thin film was washed using deionised water to remove the presence of any ions followed by annealing treatment at 400 °C for 1 hr. It was observed that the colour of the as-deposited amorphous BiVO₄ thin film changed from being a brownish gray film into a vivid yellow film after the annealing treatment.

2.3. Fabrication of orthorhombic V₂O₅ and V₂O₅/BiVO₄ photoanode

V₂O₅ thin film was obtained from a single direct anodic deposition step at 1.5 V vs Ag/AgCl (3M) from a solution of 0.2M VOSO₄ in 20mL of deionised water and 20mL of absolute ethanol for 10 min on bare FTO and FTO/BiVO₄ thin films. The final pH of the mixture was adjusted to pH 1.8 by adding H₂SO₄. Subsequently, both the thin films were annealed at 400 °C for 1 hr.

2.4. Characterisation

Both TEM and HR-TEM) images were obtained using a JEOL JEM-2100F electron microscope. UV–vis absorbance spectra were recorded using a spectrophotometer (Agilent, Cary 100) equipped with an integrated sphere. The absorbance spectra were analysed under ambient temperature within the wavelength range of 400 to 800 nm. The Raman spectra were recorded from a Raman spectrometer (Horiba Scientific) with a solid state laser operating at an excitation source of 514 nm. The crystal structures were characterised using an XRD (Bruker D8) by employing Cu-K α radiation with 40 kV and 100 mA at 0.02° s⁻¹ scan rate. XPS measurements were carried out by using a scanning X-ray microprobe PHI Quantera II (Ulvac-PHI, INC.) with a monochromatic Al-K α ($h\nu = 1486.6$ eV) X-ray source. Prior to the deconvolution of peaks, all binding energies were referenced to the adventitious carbon signal (C 1s peak) at 284.6 eV.

2.5. Electrochemical analysis

PEC measurements were carried out in a standard three-electrode assembly using an applied potentiostat/galvanostat (Metrohm PGSTAT 204 model, Netherlands), where the saturated Ag/AgCl (3M) electrode and Pt rod were used as the reference and counter electrodes, respectively. LSV scans under dark and visible light illumination were recorded. A 150 W Xenon light with an output illumination intensity of 100mW/cm² was used for the illumination with a scan rate of 10 mV/s. All the LSV scans, Nyquist plot and Mott-Schottky analyses were conducted in a 0.5 M aqueous Na₂SO₄ solution. The charge separation and charge injection properties of the photoanodes were investigated in the presence hydrogen peroxide (H₂O₂) as the

hole scavenger. EIS was conducted with a frequency range of 100 kHz–0.1 Hz at 1.2 V bias voltage. Mott-Schottky analyses were performed at 10 kHz by scanning the potential range from -0.1 to 0.9 V at 0.05 V s⁻¹ sweep rate. IMPS measurements were conducted using a potentiostat (IVIUM technology). The electrolyte used was 0.1 M aqueous Na₂SO₄ solution. Modulated illumination (LED: cool white light) was provided by a ModuLight-module (IVIUM technology). A modulation depth of ca.10 % was used and the frequency range was 10 kHz-0.1 Hz.

3. Results and Discussion

To ensure the careful interfacial engineering between BiVO₄ and V₂O₅, both TEM and HR-TEM for V₂O₅/BiVO₄ were analysed and the images are shown in Fig. 1. The TEM image of V₂O₅/BiVO₄ as shown in Fig. 1 (a) evinced the existence of BiVO₄ and V₂O₅. To further prove the formation of heterojunction and observe inner crystal structure of V₂O₅/BiVO₄ photoanode, HR-TEM was employed and the corresponding images are shown in Fig. 1 (b). The HR-TEM images clearly revealed two distinct sets of lattice fringes. One set of the fringe spacing measured at 0.308 nm was assigned to the (121) lattice spacing of monoclinic clinobisvanite BiVO₄. The second set of the fringe spacing measured at 0.207 nm was corresponded to the (010) plane of orthorhombic V₂O₅ [28, 35]. Furthermore, the HR-TEM images in Fig. 1 (c) also demonstrated the interlocked lattice fringes in the V₂O₅/BiVO₄ heterojunction structure instead of a simple mechanical mixture of two individual thin films. This is beneficial to the separation efficiency of photogenerated charge carriers and thus, leading to the improvement of photocurrent generation (results as shown later).

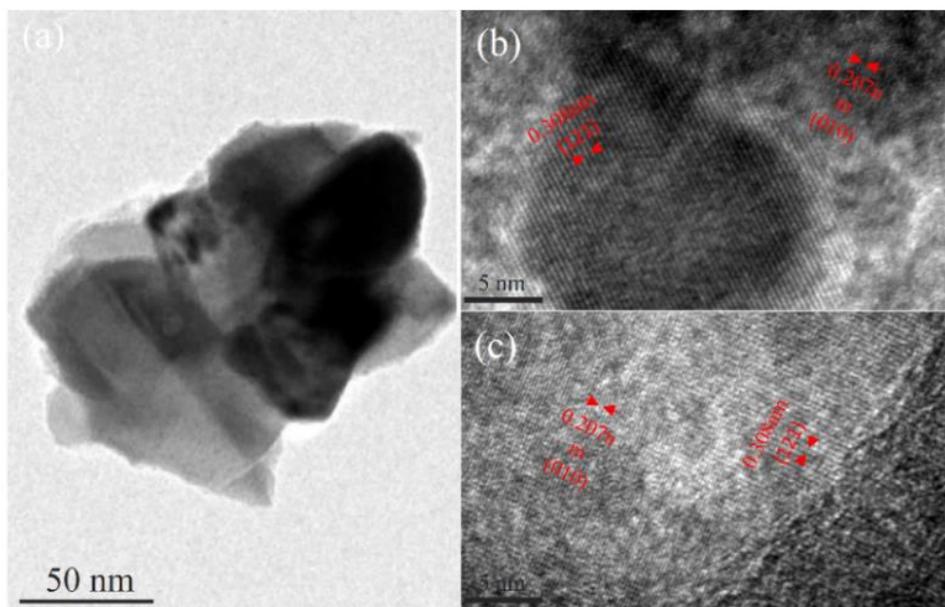


Fig. 1. (a) TEM image, (b) and (c) HR-TEM images of $V_2O_5/BiVO_4$ heterojunction photoanode.

XRD analyses were performed to verify the crystalline phases of $BiVO_4$ and V_2O_5 , and the resulting XRD diffractograms are shown in Fig. 2. From the XRD spectrum of $BiVO_4$ (red line), all the diffraction peaks of $2\theta = 18.5, 26.1, 28.6$ and 29.5° are well indexed to the monoclinic clinobisvanite $BiVO_4$ phase that is highly photoactive because of its particular crystal and electronic structure [36, 37]. On the other hand, the pristine V_2O_5 shows XRD peaks (yellow line) that could be matched to the orthorhombic V_2O_5 phase at $20.1, 21.3$ and 30.7° [38]. The XRD patterns of the composite films (green & blue lines) are nearly unchanged after forming the $V_2O_5/BiVO_4$ and $BiVO_4/V_2O_5$ heterojunction films.

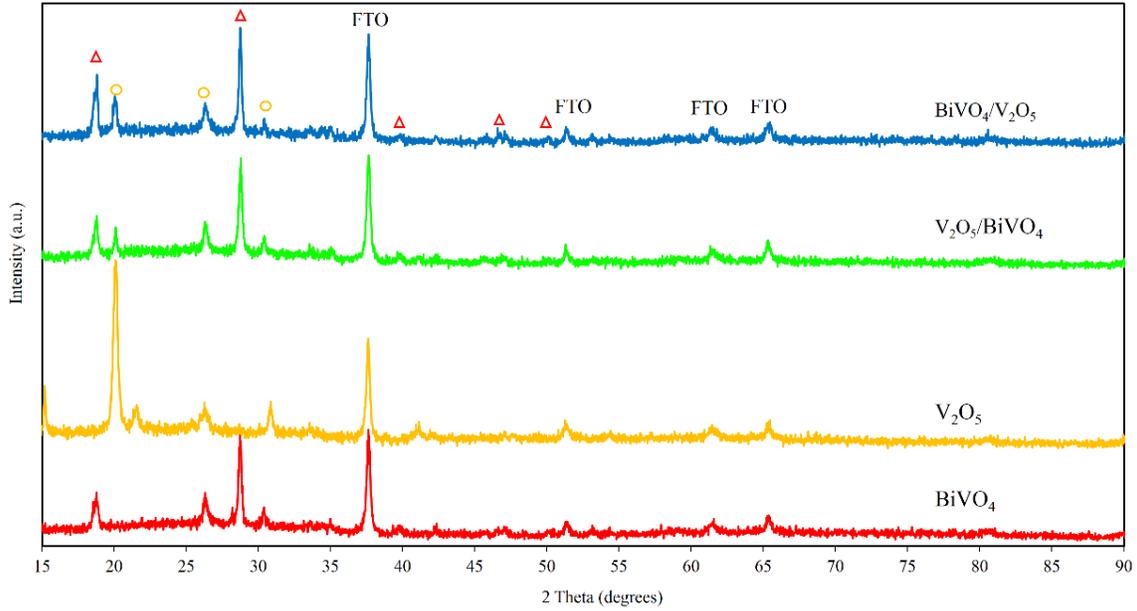


Fig. 2. XRD spectra of pristine BiVO₄, V₂O₅, V₂O₅/BiVO₄ and BiVO₄/V₂O₅ heterojunction photoanodes.

Raman spectra shown in Fig. 3 are in a good agreement with the XRD analyses. For the monoclinic clinobisvanite BiVO₄, the characteristic Raman peaks at 124, 210, 324, 363, 710 and 824 cm⁻¹ can be observed. The characteristic Raman peaks of the pristine BiVO₄ at 124 and 210 cm⁻¹ are the external mode of BiVO₄ that gives little structural information [39]. Whilst the characteristic Raman peaks at 324 and 363 cm⁻¹ are assigned to the asymmetric and symmetric deformation modes of the VO₄³⁻ tetrahedron, respectively. Lastly, the characteristic Raman peaks at 710 and 824 cm⁻¹ are attributed to the two different types of V-O stretching [40]. While for orthorhombic V₂O₅, the high wavenumber peak at 995 cm⁻¹ is caused by the stretching mode of the vanadium-oxygen double bond, V=O. The second and third peak at 700 cm⁻¹ and 526 cm⁻¹ are assigned to the V-O₁ and V-O₂ bond, respectively. Following that, the bending motion of the V-O₁ and V-O₂ bond are corresponding to the low wavenumber peaks at 480 cm⁻¹ and 302 cm⁻¹, respectively [41]. The peaks that appeared at 403 cm⁻¹ and 282 cm⁻¹ are assigned to the bending

motion of the shortest V=O bonds of the pristine V_2O_5 [42]. Last of all, the lower Raman shift peaks detected at 195 cm^{-1} and 147 cm^{-1} are caused by the vibrational movements of the V atoms [43]. From the Raman analyses, there is no change of band position was observed after the formation of heterojunction films. Based on the XRD and Raman analyses, it can be concluded that the monoclinic clinobisvanite $BiVO_4$ and orthorhombic V_2O_5 were successfully synthesized leading to the then formation of heterojunction films of $BiVO_4/V_2O_5$ and $V_2O_5/BiVO_4$.

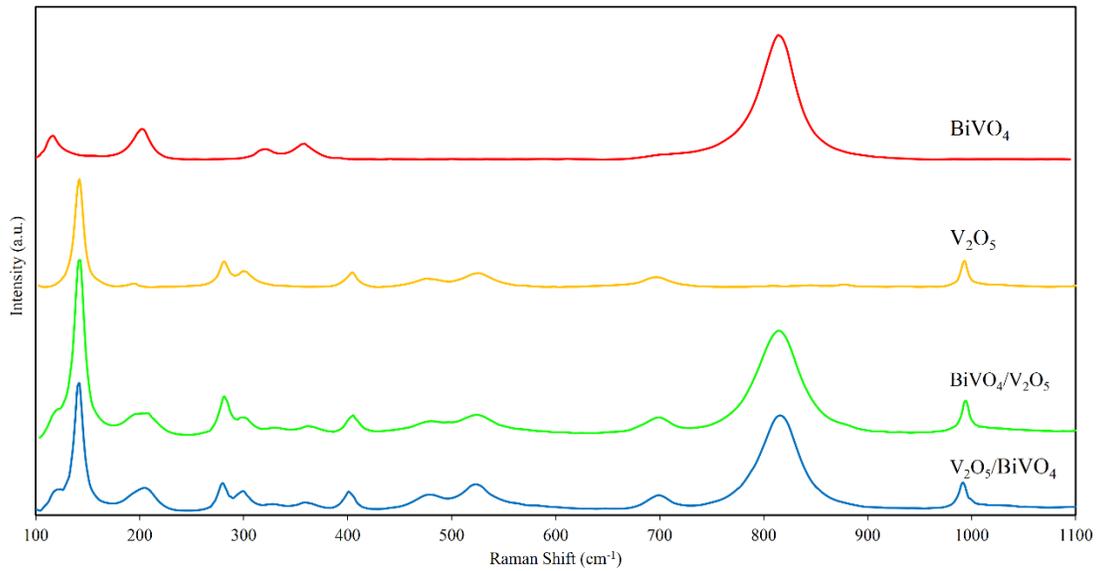


Fig.3. Raman spectra of $BiVO_4$, V_2O_5 , $V_2O_5/BiVO_4$ and $BiVO_4/V_2O_5$ heterojunction photoanodes.

Additional insights into the chemical compositions of the $V_2O_5/BiVO_4$ heterojunction photoanode were further revealed through XPS analysis. Fig. 4(a) shows the overall XPS spectrum of $V_2O_5/BiVO_4$ heterojunction photoanode, revealing the presence of Bi, C, O, Sn and V elemental characteristic peaks. The observed peaks of C 1s at 284.6 eV and Sn 3d at 486.60 and 495.02 eV are attributed to the signals from carbon in instrument and FTO substrate, respectively. Whilst the peak of O 1s at 529 eV is corresponding to the O^{2-} anions.

The high resolution XPS spectrum (Fig. 4b) of Bi 4f region for V₂O₅/BiVO₄ heterojunction photoanode shows two main peaks with the binding energies of 158.9 and 164.2 eV, which are attributed to the Bi 4f_{5/2} and Bi 4f_{7/2}, respectively. In the observed V 2p spectra shown in Fig. 4 (c), the V 2p_{2/3} and V 2p_{1/2} peaks that locate at different positions are due to the different chemical environment of the V⁵⁺ cations in BiVO₄ and V₂O₅. The V⁵⁺ cations in BiVO₄ and V₂O₅ are denoted as V₁ and V₂, respectively. V₁ gives rise to the V 2p_{2/3} and V 2p_{1/2} peaks at 517.2 and 524.2 eV, respectively while the V₂ peak has binding energy at 517.7 and 525.3 eV.

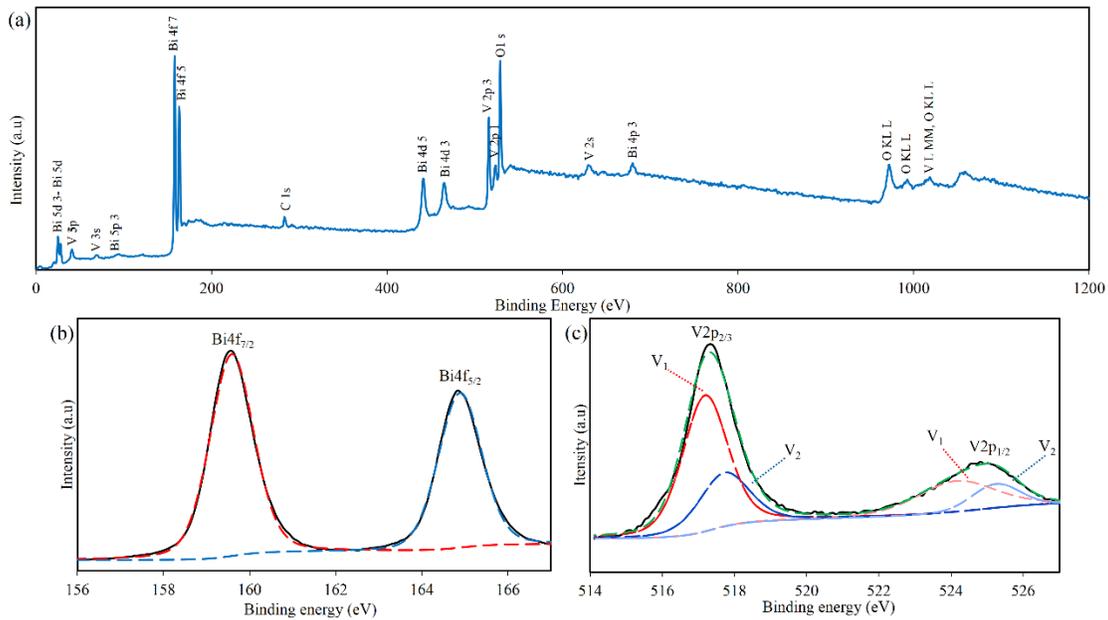


Fig.4: (a) Overall XPS spectrum of V₂O₅/BiVO₄ heterojunction photoanode. XPS spectra of (b) Bi 4f and (c) V 2p of V₂O₅/BiVO₄ heterojunction photoanode.

LSV were carried out to assess the effect of forming a heterojunction between BiVO₄ and V₂O₅ on the photocurrent generation potential. Fig. 5 (a) shows that the photocurrent increases with the increase in applied anodic potential under light irradiation, indicating that pristine BiVO₄ and V₂O₅ exhibit the *n*-type semiconductor characteristic. For the pristine BiVO₄ photoanode, the

onset potential under light irradiation was measured to be 0.3 V vs. Ag/AgCl. The highest photocurrent density of 0.22 mA/cm² at 1.5 V vs Ag/AgCl was measured for pristine BiVO₄. When a V₂O₅ thin film was introduced on top of BiVO₄, the resulting BiVO₄/V₂O₅ heterojunction structure yielded a photocurrent density of 0.42mA/cm² at 1.5 V vs Ag/AgCl that was a 2.5-fold increase in photocurrent density than the pristine BiVO₄. Interestingly, the photocurrent density of reverse order V₂O₅/BiVO₄ heterojunction photoanode was measured to be 1.53 mA/cm² at 1.5 V vs Ag/AgCl. In this instance, the photocurrent density of V₂O₅/BiVO₄ heterojunction photoanode achieved a 6.9-fold and a 7.3-fold improvement over the individual pristine BiVO₄ (0.22 mA/cm²) and V₂O₅ (0.21 mA/cm²), respectively. After forming the heterojunction structures, the photocurrent density did not reach saturation even at the applied potentials of more than 1.5 V vs Ag/AgCl where the dark current was measured relatively low at 0.02 mA/cm². The enhancement in photocurrent generation was attributed to the improved charge injection efficiency in the heterojunction photoanode by using H₂O₂ aqueous solution as the hole scavenger. The role of H₂O₂ is to manifest the photocurrent to be solely generated from the bulk, without the interference of surface recombination that occurs at the electrode-electrolyte interface. Therefore, the enhanced photocurrent shown in Fig. 5 (b) of V₂O₅/BiVO₄ when compared to pristine BiVO₄ is due to the promising effect of V₂O₅ in promoting effective transfer of photogenerated charge carriers. Besides, the onset potential of V₂O₅/BiVO₄ was cathodically shifted towards a lower potential value, indicating an augmented band bending effect in the vicinity of BiVO₄/electrolyte interface that facilitates the migration of holes from bulk to interface [44].

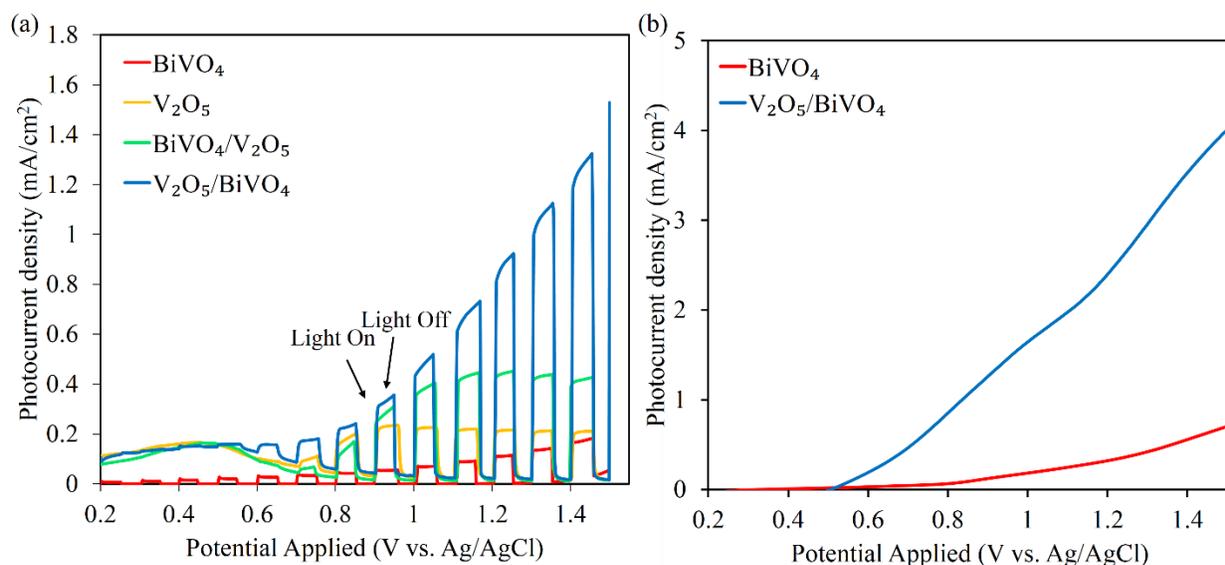


Fig. 5. (a) LSV curves of BiVO₄, V₂O₅, V₂O₅/BiVO₄ and BiVO₄/V₂O₅ heterojunction photoanodes under chopped light irradiation. (b) LSV curves of pristine BiVO₄ and V₂O₅/BiVO₄ photoanodes in the presence of H₂O₂ hole scavenger in 0.5 M Na₂SO₄ electrolyte.

Fig. 6 shows the chronoamperometric comparison of pristine BiVO₄ and V₂O₅, and heterojunction structures of BiVO₄/V₂O₅ and V₂O₅/BiVO₄ under chopped light irradiation with an irradiated surface area of 2.4 cm² at a constant applied potential of 1 V vs Ag/AgCl. Photocurrent decay (i.e. anodic peak) was observed for pristine BiVO₄ and V₂O₅/BiVO₄ upon initial light irradiation. The occurrence of anodic peak is associated with rapid surface recombination due to the built-up of photogenerated holes and slower charge transfer process at the photoanode-electrolyte interface. The surface recombination of photogenerated charge carriers is usually caused by either the accumulation of electrons or holes in the bulk and at the surface, respectively. However, cathodic peak can barely be observed when the light is switched off. Its presence is usually attributed to the back reaction of minority charge carriers that are trapped at the surface of conduction band. V₂O₅/BiVO₄ achieved 0.268 mA/cm², which was 22

times than the pure BiVO_4 (0.012 mA/cm^2), 1.4 times than pure V_2O_5 (0.185 mA/cm^2) and 1.2 times than $\text{BiVO}_4/\text{V}_2\text{O}_5$ (0.225 mA/cm^2) after under light irradiation of 5 min. This indicates that the heterojunction structure of $\text{V}_2\text{O}_5/\text{BiVO}_4$ is more photoactive, as it allows electron injection from BiVO_4 into V_2O_5 and overcomes the high bulk and surface recombination rate of pristine BiVO_4 .

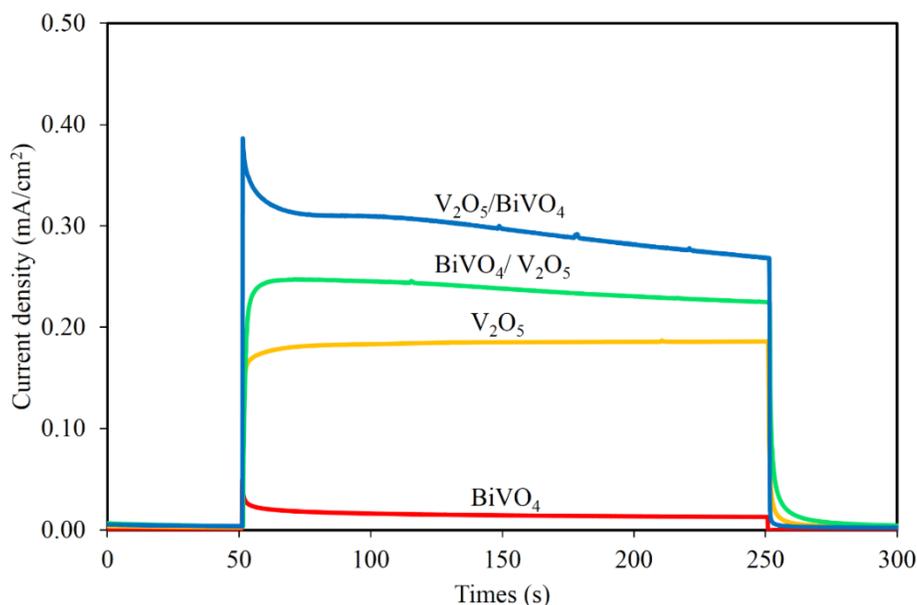


Fig. 6. Transient photocurrent response measured at an applied potential of 1V vs Ag/AgCl.

Following this, EIS Nyquist analysis was carried out to gain further insights into the photogenerated charge carriers transfer process in the heterojunction structures. Fig. 7 shows the Nyquist plot, where the real part of impedance (Z') is located on the z-axis (Ω) while the imaginary part of impedance (Z'') is located on the y-axis (Ω). From Fig. 7, the spheres represent the experimental data points while the lines are the fitted simulation electrochemical impedance responses according to the equivalent circuit model used. Generally, the arc radius of the Nyquist plot provides information on the interfacial layer resistance and charge transfer properties of the

photoanode [45]. A larger diameter of arc radius implies that the charge transfer is a limiting process, and this can be ascribed to the charge transfer resistance at the photoanode-electrolyte junction. Whilst the smaller diameter of arc radius reveals the lower charge transfer resistance, which intuitively will promote a better migration of photogenerated charge carriers. Fig. 7 (inset) shows the Randles-Ershel model equivalent circuit consisting of the solution resistance (R_s), constant phase element (Q) and charge transfer resistance across the interface (R_{ct}) together with their fitted values. With the rational design of heterojunction photoanodes in this study, R_{ct} for $V_2O_5/BiVO_4$ was significantly reduced by 2 fold. This will have a direct influence on the efficient transfer of photogenerated charge carriers at the photoanode-electrolyte interface, which could be further induced by the constructed band alignment between the semiconductors of V_2O_5 and $BiVO_4$. However, EIS analysis is not directly applicable for the photoanode-electrolyte interface due to the potential variations that appear mainly across the space charge region of the semiconductor rather than across the Helmholtz layer. Therefore, IMPS was used to analyse the direct competition between photogenerated holes transfer and surface recombination at the photoanode-electrolyte interface by modulating the light intensity.

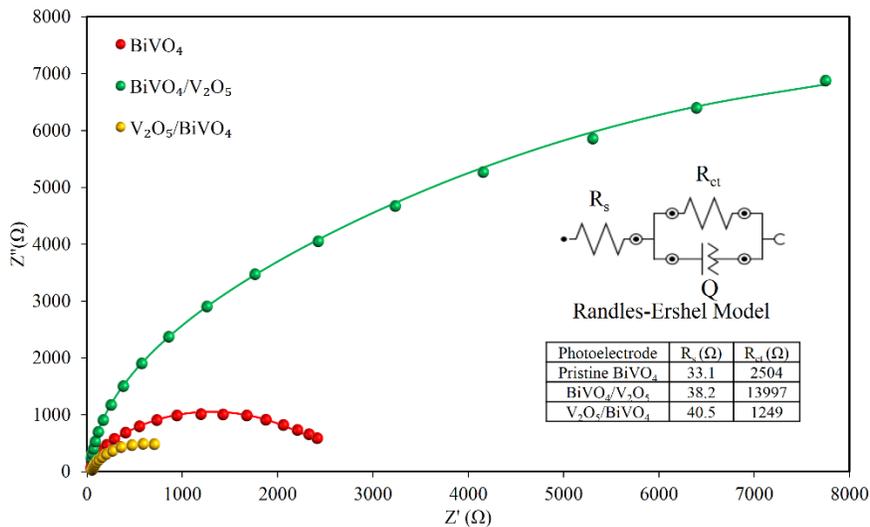


Fig. 7. Electrochemical impedance spectroscopy (EIS) Nyquist plots for BiVO₄-based heterojunction photoelectrode under simulated light irradiation. The upper-right inset is the equivalent electric circuit the EIS fitting values of the equivalent circuit model parameters.

In principal, the rate constants of surface recombination (K_r) and charge transfer (K_t) can be obtained by analysing the transient photocurrent responses. In practice, however, IMPS is a more robust measurement method used to characterise charge transfer and surface recombination. IMPS involves the modulation of light intensity while simultaneously measuring the magnitude and phase of the photocurrent response as a function of frequency [46]. The modulated irradiation will result in the generation minority carrier fluxes into the photoanode-electrolyte interface, which will subsequently be involved in the charge transfer reaction or combination with the majority carriers. The main advantage of IMPS is that it involves a small amplitude modulation (typically <10 % of the DC irradiation level) and hence, the changes in band bending induced by irradiation are minimised [47]. Fig. 8 (a) shows the IMPS spectra for pristine BiVO₄ under AM 1.5 simulated solar light irradiation. At low frequency, the semicircle located in the upper quadrant of the complex plane is known as the “recombination semicircle” because it is dominated by the surface recombination [48]. Meanwhile, the imaginary component of photocurrent reaches the maximum when the frequency (ω_{max}) matches with the characteristic relaxation constant of the system:

$$\omega_{max} = K_r + K_t$$

where K_r and K_t are the pseudo-first order charge transfer (s^{-1}) and recombination rate constants (s^{-1}), respectively. At high frequency, the response is attenuated by the total resistance in series, combined space charge and Helmholtz capacitance of the photoanode sample [48]. The radial frequency corresponding to the maximum in the semicircle is equal to $K_r + K_t$, and the ratio of

the low-to-high frequency intercept is used to estimate the charge transfer efficiency ($\frac{K_t}{K_r+K_t}$) [46]. From Fig. 8 (a), the ratio of the low-to-high frequency intercept increases as the applied bias potential is increased for pristine BiVO₄ photoanode. This response is expected due to the charge transfer efficiency and recombination is decreased at higher positive potential. Whilst Fig. 8 (b) shows that the K_r of pristine BiVO₄ photoanode is much larger than K_t and there are no significant decrement of the K_r by increasing the applied potential. Based on the complex IMPS plot for pristine BiVO₄ photoanode, it can be observed that the performance of pristine BiVO₄ photoanode is limited by the severe charge recombination on photoanode surface. Fig. 8 (c) shows that the IMPS responses of heterojunction photoanodes of V₂O₅/BiVO₄ and BiVO₄/V₂O₅, where recombination semicircles are absent at the upper quadrant. This is due to the microwave reflectivity that detects the decay of photogenerated charge carriers located at the photoanode surface, regardless of whether they are transferred across the interface or recombine with the majority carriers [49]. In this instance, the good separation efficiency of photogenerated electrons and holes in the heterojunction photoanodes leads to the vast improvement in photocurrent generation potential.

Additionally, the transit time (τ) of photogenerated charge carriers within the studied photoanode structures could also be estimated through the frequency at the apex of lower RC semicircle in the IMPS response:

$$\tau = (2\pi\mu f_{max})$$

where f_{max} is the minimum characteristic frequency of the IMPS response at the imaginary plots. Through estimation, the transit time (τ) for photo-injected electrons in the heterojunction photoanodes of V₂O₅/BiVO₄ and BiVO₄/V₂O₅ reaching the back contact are 6.4 ms and 26.5 ms,

respectively. In conclusion, the photogenerated charge carriers transfer in heterojunction structures are varying to an extent that is determined by the band alignment and the $V_2O_5/BiVO_4$ is proven favorable in terms of fast charge transport and high photocurrent generation potential.

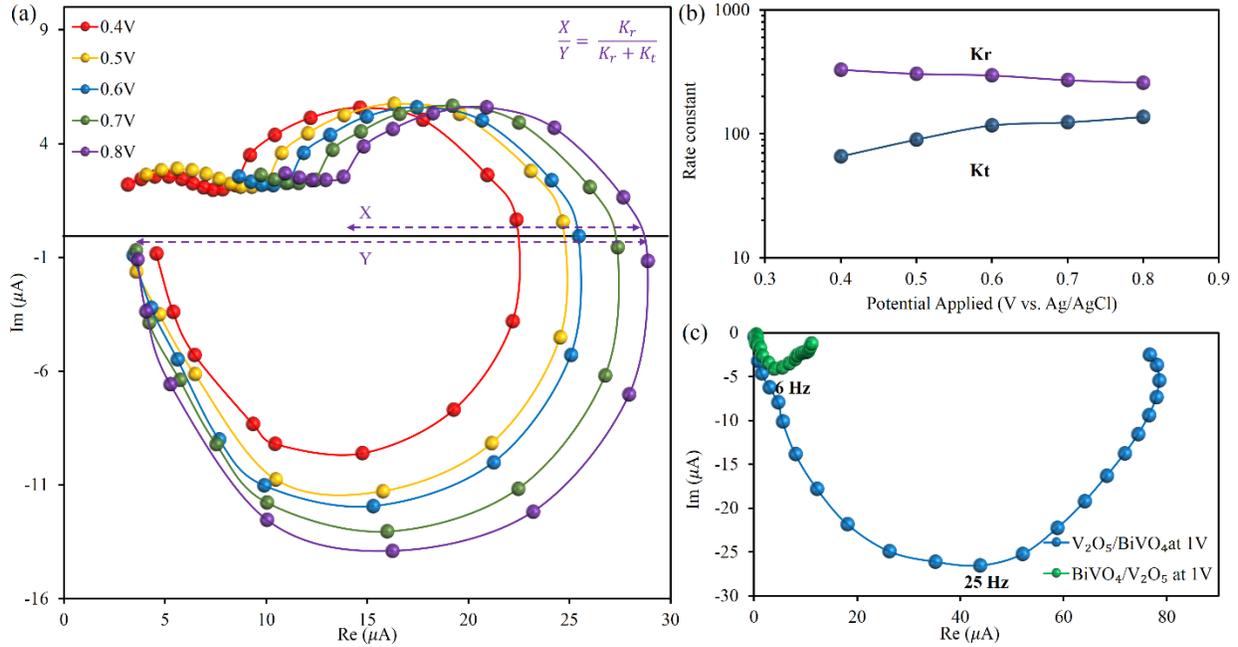


Fig. 8. (a) IMPS spectra of pristine $BiVO_4$ photoanode under different applied bias potentials under AM 1.5 simulated solar light irradiation in 0.1 M Na_2SO_4 electrolyte solution. (b) Potential dependence of the rate constants K_t and K_r for pristine $BiVO_4$ photoanode. (c) IMPS spectra of $V_2O_5/BiVO_4$ and $BiVO_4/V_2O_5$ measured at an applied potential of 1 V vs Ag/AgCl.

Finally, both the experimental Mott-Schottky analysis and Tauc plots were carried out to determine the flat-band potential (E_{fb}) and band gap energy for pristine $BiVO_4$ and V_2O_5 . These will enable the reconstruction of theoretical band diagram for pristine $BiVO_4$ and V_2O_5 and heterojunction structures of $V_2O_5/BiVO_4$ and $BiVO_4/V_2O_5$ in determining their respective band alignment and heterojunction type. Furthermore, the reconstruction of theoretical band diagram also serves as an important basis used to elucidate the mechanism of photogenerated charge

carriers transfer in the much improved heterojunction structures. From Fig. 9 (a) and (b), it can be observed that the positive slopes of Mott-Schottky plots for BiVO₄ and V₂O₅ indicate that both of the semiconductors exhibit the *n*-type behavior. The estimated E_{fb} for pristine BiVO₄ and V₂O₅ were 0.35 V and 0.56 V, respectively. From Fig. 9 (c), the extrapolated straight lines are indicating that the absorption edge is due to a direct allowed transition. The intersection of the straight lines on $h\nu$ axis corresponds to the band gap energy. The band gaps for pristine BiVO₄ and V₂O₅ were estimated to be approximately 2.6 eV and 2.49 eV, respectively. Working in conjugation with their E_{fb} , a theoretical band diagram for pristine BiVO₄ and V₂O₅ semiconductors are reconstructed from the experimental data and depicted in Fig. 9 (d). Based on the theoretical band diagram, a plausible mechanism of photogenerated charge carriers transfer in heterojunction photoanodes is schematically illustrated in Fig. 9 (e). Upon light irradiation for the heterojunction V₂O₅/BiVO₄ photoanode, the photogenerated electrons in CB of BiVO₄ migrate to the CB of V₂O₅. These electrons will eventually be transferred to the Pt counter electrode for the reduction of hydrogen ions (H⁺) into molecular H₂ gas. On the other hand, the photogenerated holes at the VB of V₂O₅ migrate to the CB of BiVO₄ and further oxidise water molecules to produce molecular O₂ gas. As a result, the thermodynamic condition enabled the photogenerated electrons to concentrate on V₂O₅ and the holes on BiVO₄, efficiently facilitating the charge separation and thus enhance the PEC performance. However, for the inverse arrangement photoanode (BiVO₄/V₂O₅), some of the photogenerated electrons at the CB of BiVO₄ migrate to the substrate while some of the electrons migrate and accumulate to the CB of V₂O₅. Due to the band positions and seclusion from the electrolyte, the photogenerated holes at the VB of V₂O₅ are accumulating at the VB of BiVO₄ as a result of causing the recombination of the photogenerated electrons and holes at BiVO₄. On the basis of the above-mentioned energy

band structure, charge transfer in the Type II staggered heterojunction structures of $V_2O_5/BiVO_4$ led to a high separation efficiency of electron-hole pairs and the subsequent enhance in photocurrent generation.

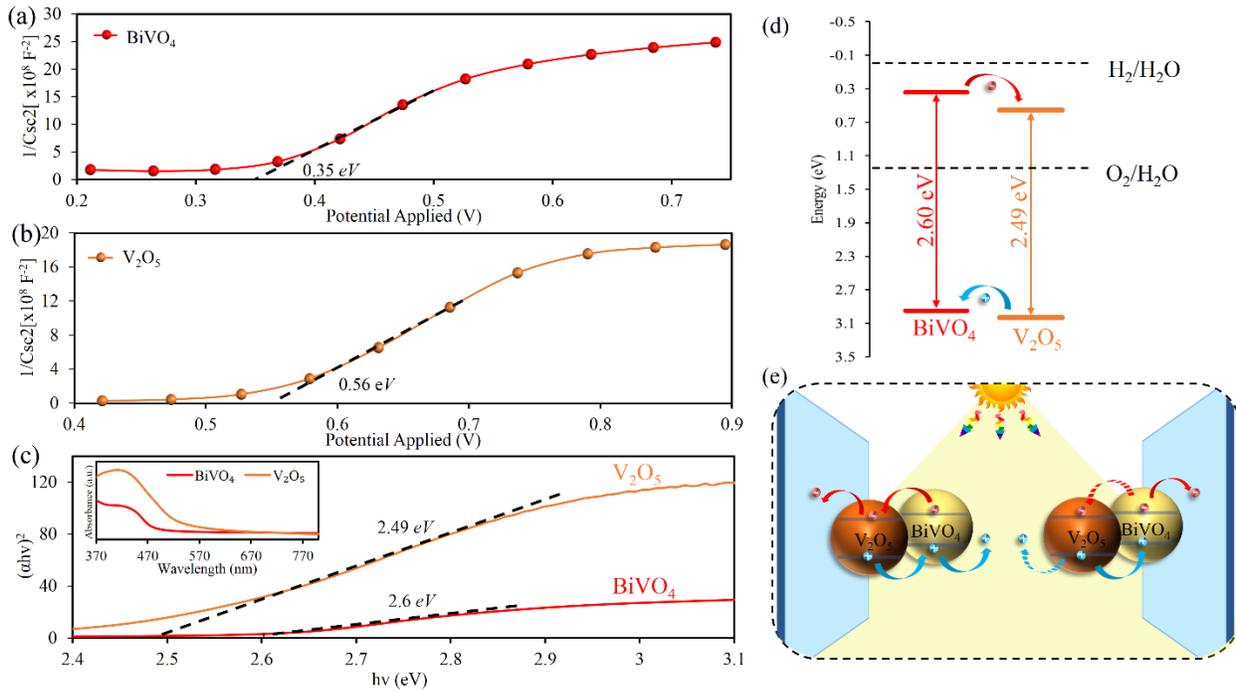


Fig. 9. Band gap characterisations of as-prepared samples: Mott-Schottky plots for pristine (a) $BiVO_4$ and (b) V_2O_5 . (c) Tauc plot for the pristine $BiVO_4$ and V_2O_5 and inset displaying UV-vis diffuse reflectance spectra of $BiVO_4$ and V_2O_5 . (d) Estimated relative band positions of pristine $BiVO_4$ and V_2O_5 . (e) Schematic of proposed electron/hole transfer mechanism for different sequence arrangement of $BiVO_4$ -based heterojunction photoelectrodes.

4. Conclusion

In conclusion, a highly efficient *n-n* Type II staggered $V_2O_5/BiVO_4$ heterojunction photoanode was successfully synthesized by studying the synergistic effect of band potentials matching and conductivity difference between pristine $BiVO_4$ and V_2O_5 thin films. Two different

heterojunction photoanode arrangements of BiVO₄/V₂O₅ and V₂O₅/BiVO₄ were systematically examined, and it was proven through Nyquist and IMPS analysis that V₂O₅/BiVO₄ exhibited a more effective separation of photogenerated charge carriers and rapid interfacial charge transfer. The V₂O₅/BiVO₄ heterojunction photoanode achieved a significantly improved photocurrent density of 1.53 mA/cm² at 1.5 V vs Ag/AgCl than the individual pristine BiVO₄ (0.22 mA/cm²) and V₂O₅ (0.21 mA/cm²). The improvement in the PEC performance was attributed to the wider utilisation of solar spectrum, efficient separation of photogenerated charge carriers, as well as improved charge mobility as evidenced from the much shorter transit time for the migration of photogenerated electrons to the counter electrode. As a whole, our study has demonstrated a facile electrodeposition method to fabricate a more efficient BiVO₄ based-heterojunction photoanode as well as chemical physics surrounding the transfer of photogenerated charge carriers within the structure. It is believed that this will pave way towards developing a highly efficient BiVO₄ based-heterojunction photoanode for practical application in PEC water oxidation in the near future.

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